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## **CONFIRMATION NO. 7343**

FILING DATE 04/01/2004 RULE	C	CLASS 250			UNIT		ATTORNEY OCKET NO. 61887-0119
APPLICANTS							
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Do-Haing Lee, Kyeonggi-do, KOREA, REPUBLIC OF; Byoung Jae Park, Chungcheongnam-do, KOREA, REPUBLIC OF;							
** CONTINUING DATA **********************************							
** FOREIGN APPLICATIONS ************************************							
IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** SMALL ENTITY ** ** 06/16/2004							
Foreign Priority claimed  35 USC 119 (a-d) conditions  met  Verified and Acknowledged  Acknowledged		STATE OR  COUNTRY  KOREA,  REPUBLIC  OF	SHEETS DRAWING 7				INDEPENDENT CLAIMS 1
ADDRESS 22428 FOLEY AND LARDNER SUITE 500 3000 K STREET NW WASHINGTON, DC 20007							
TITLE 3-Grid neutral beam source used for etching semiconductor device							
LING FEE FEES: Authority has been given in Paper No to charge/credit DEPOSIT ACCOUNT ECEIVED No for following: 385				All Fees  1.16 Fees (Filing)  1.17 Fees (Processing Ext. of time)  1.18 Fees (Issue)  Other			
	O4/01/2004  RULE  ROM, Seoul, KOREA, R. Kyeonggi-do, KOREA, Ick, Chungcheongnam-do  RTIONS  ROREA 10-2004-0013  GON FILING LICENSE  Wyes no Met after  Allowappe Indi  Miner's Signature Indi  RR  Ource used for etching seconds.	RULE  ROM, Seoul, KOREA, REPUBLIC  Kyeonggi-do, KOREA, REPUBLIC  K, Chungcheongnam-do, KORE  K, Chungcheongnam-do, KORE  KOREA 10-2004-0013484 02/2  GIGN FILING LICENSE GRANTE  Wes no Met after  Allowapse Ino Met after  Allowapse Initials  R  Durce used for etching semicond  S: Authority has been given in P	RULE  CLASS 250  RULE  COM, Seoul, KOREA, REPUBLIC OF;  Kyeonggi-do, KOREA, REPUBLIC OF;  k, Chungcheongnam-do, KOREA, REPUBLIC  A ***********************************	RULE  CLASS 250  RULE  COM, Seoul, KOREA, REPUBLIC OF;  Kyeonggi-do, KOREA, REPUBLIC OF;  k, Chungcheongnam-do, KOREA, REPUBLIC OF;  KTIONS  CTIONS  CTIONS  COMPANY  COUNTRY  FOR Allowage In Death of the Month of the Country  Minier's Signature  COUNTRY  KOREA, REPUBLIC  OF  COUNTRY  KOREA, REPUBLIC  OF  R  COUNTRY  KOREA, REPUBLIC  OF  COUNTRY  KOREA  COUNTRY  COUNTRY  KOREA  COUNTRY  C	RULE  COM, Seoul, KOREA, REPUBLIC OF;  (Yeonggi-do, KOREA, REPUBLIC OF; (Xyeonggi-do, KOREA, REPUBLIC OF; (X, Chungcheongnam-do, KOREA, REPUBLIC OF; (X) STATE OF; (X) STATE OR SHEETS (X) STATE OR SHEETS (X) SIgnature Initials REPUBLIC OF; (X) COUNTRY (X) COU	RULE  COM, Seoul, KOREA, REPUBLIC OF;  Kyeonggi-do, KOREA, REPUBLIC OF;  K, Chungcheongnam-do, KOREA, REPUBLIC OF;  K, Chungcheongnam-do, KOREA, REPUBLIC OF;  KOREA 10-2004-0013484 02/27/2004  GON FILING LICENSE GRANTED ** SMALL ENTITY **  COUNTRY  KOREA,  REPUBLIC  OF  STATE OR  COUNTRY  KOREA,  REPUBLIC  OF  R  COUNTRY  KOREA,  REPUBLIC  OF  R  COUNTRY  KOREA,  REPUBLIC  OF  Allywaper  Initials  COUNTRY  KOREA,  REPUBLIC  OF  All Fees  1.16 Fees (1)  1.17 Fees (1)  1.17 Fees (1)  1.18 Fees (1)	RULE  COM, Seoul, KOREA, REPUBLIC OF; Kyeonggi-do, KOREA, REPUBLIC OF; K, Chungcheongnam-do, KOREA, REPUBLIC OF; KOREA 10-2004-0013484 02/27/2004  GIN FILING LICENSE GRANTED "SMALL ENTITY"  STATE OR  Lower Journal Country KOREA, REPUBLIC OF R  COUNTRY KOREA, REPUBLIC OF Allysage In o Met after COUNTRY KOREA, REPUBLIC OF Allysage In o Met after Allysage In o Met after COUNTRY KOREA, REPUBLIC OF R  COUNTRY KOREA, REPUBLIC OF Initials REPUBLIC OF  COUNTRY KOREA, REPUBLIC OF Initials COUNTRY KOREA, REPUBLIC OF IN THE ORIGINAL OF IN